QUICK GUIDE

Start Up

- 1. Enable the CEE APOGEE Bake Plate on the TNFC Access System.
- 2. Turn ON the machine using the button on the right.
- **3.** Login using the following credentials Username: admin Password: admin2
- 4. Confirm that the system is ready for operation by navigating to Tools>Manual Control:
 - Plate temperature: ~20 °C
 Ambient Temperature: ~22 °C
 - Lift pin height: 5.0 mm Humidity: ~31-32%
- 5. Confirm that the system is ready for operation by checking the gas valves:
 - Main nitrogen gas valve: **Optional (ONLY** open when **proximity bake** is needed)
 - Hood nitrogen valve: **Optional (ONLY** open when hood **Nitrogen purge** is needed)
 - Vacuum pump: Optional (ONLY turn on the pump next to it when vacuum bake is needed)

WARNING: Bake Plate surface might be VERY HOT, BE CAUTIOUS.

REMARKS: The plate temperature at ~20°C is just a reference temperature for the idling state. The process can still start at any plate temperature just that there might be risk of incurring process variation.

REMARKS: The lift pin height (home) can be changed according to user preference. For example, users can set the home height to 0mm through **Manual Control** and the sample will be placed on the bake plate surface directly at the start of the process.

Bake Methods

- 6. Vacuum method (Hard contact)
 - Sample is held securely to the bake plate surface through applying a **vacuum**.
 - Uniform heating across the sample surface.
 - Applicable to samples where **back side contact** is **NOT** a problem.

7. Contact method (Soft contact)

- Sample is held to the bake plate surface through gravity ONLY.
- Less uniform and less efficient heating across the sample surface.
- 8. Proximity method (Proximity contact)
 - Sample floats (1-4mm) on the bake plate surface by a thin nitrogen gas layer.
 - Slower warm-up than contact bake methods

TORONTO NANOFABRICATION CENTRE

QUICK GUIDE

- Advantages when baking thick films where **blistering** would be a problem.
- A high degree of **uniformity** even for **cambered**, or **warped** samples.

Making A New Recipe

- 9. Navigate to the Recipes Tab.
- 10. Press New.
- **11. Name** your recipe accordingly.
- **12.** Set the plate temperature by typing in the input field.
- 13. Change the time and process method (lift pin height, bake method) accordingly.
- 14. Insert more steps using the "Insert" button if it is necessary.
- **15.** Save the recipe after editing.

REMARKS: The default recipe editing mode is a relatively "simple" mode that only allows a single temperature target, users need to change to advance editing mode for purposes such as setting up a temperature ramp and holding at a certain temperature for a prolonged period.

Advance Editing Mode

- **16.** Click the "Advanced" button, a "!" is going to show up within the button, click again.
- **17. Insert** a new step using the "**Insert**" button.
- 18. Click on the newly added step.
- **19. Change** the control and the action accordingly.

REMARKS: The advance editing mode allows a high degree of freedom on controlling the process. Users can add multiple temperature target within a single process with ramping rate up to **6°C /min**. Users can also add fixed time delays to make the machine hold at a certain temperature according to their need. Changing pin height during the process is also possible.

- **20. Press "Update**" to log the change and a new step will be created.
- **21.** Organize the order of the steps using the "up" and "down" arrows.
- 22. Modify the tolerances and preconditions using their respective button if necessary.
- 23. Save the recipe after editing.

Loading And Running Existing Recipe

24. Navigate to Recipes Tab.

TORONTO NANOFABRICATION CENTRE

Please refer to the **APOGEE[™] Bake Plate Operations Manual** for more details.

QUICK GUIDE

- 25. Press "Load".
- 26. Click on the designated recipe name.
- 27. Press "Run".
- 28. Start the process using the "Start" button on the main Process Tab.

Loading A Sample

- **29. Open** the hood using the handle.
- **30.** Align and place the sample on the lift pin.
- 31. Close the hood slowly and gently.
- 32. Turn on the hood nitrogen valve if nitrogen purging is necessary.

Sample Unloading

- **33.** Once the process is **completed**, the machine will make a **beeping noise**.
- 34. Check the bake plate temperature from Tools>Manual Control.
- **35.** *Turn off* the hood nitrogen purging valve if it was opened.
- **36.** Open the hood ONLY when it is cooled down to a safe temperature.
- WARNING: The hood handle might be HOT when the interior temperature is HIGH, BE CAUTIOUS.

REMARKS: It may take some time for it to cool down, please **BE PATIENT**.

37. *Remove* the sample from the bake plate.

Shut Down

38. Confirm that the gas valves & vacuum are off:

- Main nitrogen gas valve: OFF
- Hood nitrogen valve: OFF
- Vacuum pump: OFF
- **39. Logout** from the bake plate by **admin>Log Out**.
- **40.** Turn OFF the machine using the **right** button.
- 41. Disable the CEE Apogee Bake Plate on the TNFC Access System.